

AUG 11 2006

020732-110.694

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re United States Patent Application of:

Applicant: KORZENSKI, Michael B., et al.

Application No.: 10/807,858

Date Filed: March 24, 2004

Title: COMPOSITION USEFUL FOR
REMOVAL OF BOTTOM
ANTI-REFLECTION
COATINGS FROM
PATTERNED ION-
IMPLANTED PHOTORESIST
WAFERS

Docket No.: 020732-110.694

Examiner: AHMED, Shamim

Art Unit: 1765

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24239

FACSIMILE TRANSMISSION CERTIFICATE

Attn: Examiner Shamim Ahmed

Fax No. (571) 273-8300

I hereby certify that this document is being filed in the United States Patent and Trademark Office, via facsimile transmission to Mail Stop Amendment, Commissioner for Patents, PO Box 1450, Alexandria, VA 22313-1450, on August 11, 2006, to United States Patent and Trademark Office facsimile transmission number (571) 273-8300.

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Number of Pages (including cover)



Lillian Glenn

August 11, 2006

Date

AMENDMENT RESPONDING TO MAY 11, 2006 OFFICE ACTION IN UNITED STATES PATENT APPLICATION NO. 10/807,858

Mail Stop Amendment
Commissioner for Patents
PO Box 1450
Alexandria, VA 22313-1450

Sir:

This responds to the May 11, 2006 Office Action in the above-identified application.

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Please amend the claims of the application as set out in the following **Section I (Amendments to the Claims)**.

Remarks addressing the substance of the May 11, 2006 Office Action are set out in the **Section II (Remarks)** hereof.